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(iii) a short biography of 50-100 words plus a portrait photo by Dec. 20, 2019

Applying for ITO deposition on a-Si:H passivating layer  
using four targets facing sputtering cathode and its effect

Hiroshi Iwata

Head of R&D, Director

Keihin Ramtech Co., Ltd.

- I am responsible for R&D of Keihin Ramtech Co.,Ltd.

- I developed a low damage sputtering cathode in this company.

- I have an experience of sputtering over 33 years.

- I have a lot of patent about sputtering in several companies.

- I graduated Department of Material Chemistry, Faculty of Engineering, Yokohama National University in 1984.

- I am also a student of Doctorate course in Graduate School of Yokohama National University.

